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**PATENT NUMBER and
ISSUE DATE**

U.S. UTILITY Patent Application

APPL NUM 10079348	FILING DATE 02/20/2002	CLASS 430	SUBCLASS 18	GAU 1752	EXAMINER ASHTON
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****APPLICANTS:** Lee Geun; Jung Jae; Shin Ki;

****CONTINUING DATA V**

Rev'd leave complete ASAP.

Mark

**** FOREIGN APPLICATIONS VERIFIED:**

REPUBLIC OF KOREA 2001-34603 06/19/2001

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials		ATTORNEY DOCKET NO 30205/38082
TITLE : Photoresist monomers, polymers thereof and photoresist compositons containing the same <small>U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)</small>		

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner PREPARED FOR ISSUE Applicati n Examiner	
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